Search Notes

Application/Control No.	Applicant(s)/Patent under Reexamination	on	
10/631,952	KLASS, EDGARDO F.		
Examiner	Art Unit		
Hai L. Nguyen	2816		

Hai L. Nguyen

SEARCHED					
Class	Subclass	Date	Examiner		
327	165,166, 170-176, 291-295, 297	1/31/2005	HLN		
327	105,107	1/31/2005	HLN		
327	141,144	1/31/2005	HLN		
327	145	1/31/2005	HLN		
326	93,96	1/31/2005	HLN		

INTERFERENCE SEARCHED				
Class	Subclass	Date	Examiner	
Search	Above	1/31/2005	HLN	
	1			

SEARC (INCLUDING SE)
	DATE	EXMR
Shepardize Search	1/31/2005	HLN
EAST Text Search	1/31/2005	HLN